

## EAST Search History

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
S1	2	"6355702"	US-PGPUB; USPAT	OR	OFF	2008/03/14 21:59
S2	1	("20040104196").PN.	US-PGPUB; USPAT	OR	OFF	2008/03/14 22:02
S3	843	(430/280.1).CCLS.	US-PGPUB; USPAT	OR	OFF	2008/03/14 22:04
S4	323	S3 and tert	US-PGPUB; USPAT	OR	OFF	2008/03/14 22:04
S5	4839	isobornyl adj acrylate	US-PGPUB; USPAT	OR	OFF	2008/03/15 13:56
S6	2880686	s S5 with photoacid	US-PGPUB; USPAT	OR	OFF	2008/03/15 13:56
S7	1	S5 with photoacid	US-PGPUB; USPAT	OR	OFF	2008/03/15 13:56
S8	393	isobornylacrylate	US-PGPUB; USPAT	OR	OFF	2008/03/15 13:58
S9	5117	S5 or S8	US-PGPUB; USPAT	OR	OFF	2008/03/15 13:58
S10	199	S9 and (photoacid photo adj acid)	US-PGPUB; USPAT	OR	OFF	2008/03/15 13:58
S11	57	S9 and (photoacid photo adj acid) and (negativ\\$ or photonegativ\\$)	US-PGPUB; USPAT	OR	OFF	2008/03/15 14:02
S12	1	("5476752").PN.	US-PGPUB; USPAT	OR	OFF	2008/03/15 14:45
S13	0	("epikoteadj828withepoxy").PN.	US-PGPUB; USPAT	OR	OFF	2008/03/15 14:53
S14	39	tricyclo with decanyl with (acrylate methacrylate)	US-PGPUB; USPAT	OR	OFF	2008/03/15 15:58
S15	1597	(stereolith\\$10 stereo:lit\\$10 optic\\$10 near5 mold\\$5 rapid adj prototyping) and (degrad\\$ photodegrad\\$) and (epoxy diepoxy epoxide diepoxide)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2008/03/15 16:51
S16	682	(stereolith\\$10 stereo:lit\\$10 optic\\$10 near5 mold\\$5 rapid adj prototyping) and (degrad\\$ photodegrad\\$) and (epoxy diepoxy epoxide diepoxide) and (acrylate methacrylate)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2008/03/15 16:52
S17	311	(stereolith\\$10 stereo:lit\\$10 optic\\$10 near5 mold\\$5 rapid adj prototyping) and (degrad\\$ photodegrad\\$) and (epoxy diepoxy epoxide diepoxide) and (acrylate methacrylate) and (tert tertiary)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2008/03/15 16:52

S18	274	(stereolith\$10 stereo:lit\$10 optic\$10 near5 mold\$5 rapid adj prototyping) and (degrad\$ photodegrad\$) and (epoxy diepoxy epoxide diepoxide) and (acrylate methacrylate) and (tert tertiary) and (photoa\$ photob\$ photoc\$ photod\$ photoe\$ photof\$ photog\$ photoh\$ photoi\$ photoj\$ photok\$ photol\$ photom\$ photon\$ photoo\$ photop\$ photoq\$ photor\$ photos\$ photot\$ photou\$ photov\$ photow\$ photoX\$ photoY\$ photoZ\$ photo)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2008/03/15 16:53
S19	49	("3812559"   "3818191"   "4264152"   "4287410"   "4596919"   "4714310"   "4752498"   "4929402"   "5004311"   "5089185"   "5137800"   "5198159"   "5230986"   "5236637"   "5420441"   "5424838"   "5474719"   "5493444"   "5512328"   "5514519"   "5536467"   "5545367"   "5622811"   "5626919"   "5658063"   "5664255"   "5677107"   "5691541"   "5870176").PN. OR ("6200646").URPN.	US-PGPUB; USPAT; USOCR	OR	OFF	2008/03/15 17:34
S20	149	(stereolith\$10 stereo:lit\$10 optic\$10 near5 mold\$5 rapid adj prototyping) and (degrad\$ photodegrad\$) and "430"/\$.ccls.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2008/03/15 18:31
S21	5	(stereolith\$10 stereo:lit\$10 optic\$10 near5 mold\$5 rapid adj prototyping) and (degrad\$ photodegrad\$) and "430"/280.1. ccls.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2008/03/15 18:35
S22	703	photodegrad\$ and (epoxy diepoxy epoxide diepoxide) and (acrylate methacrylate)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2008/03/15 18:41
S23	1032	acid near5 degrad\$ and (epoxy diepoxy epoxide diepoxide) and (acrylate methacrylate) and (photoa\$ photob\$ photoc\$ photod\$ photoe\$ photof\$ photog\$ photoh\$ photoi\$ photoj\$ photok\$ photol\$ photom\$ photon\$ photoo\$ photop\$ photoq\$ photor\$ photos\$ photot\$ photou\$ photov\$ photow\$ photoX\$ photoY\$ photoZ\$ photo )	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2008/03/15 18:54
S24	0	"20030780662"	US-PGPUB; USPAT	OR	OFF	2008/03/16 11:46
S25	2	("20030180662").PN.	US-PGPUB; USPAT; DERWENT	OR	OFF	2008/03/16 11:46
S26	1	2000-062668.NRAN.	DERWENT	OR	OFF	2008/03/16 11:47

S28	27779	(stereolith\$10 stereo:lit\$10 optic\$10 near3 mold\$5 rapid adj prototyping)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2008/03/16 14:34
S29	758	(PHOTOACID PHOTO ADJ ACID SULFONIUM IODONIUM ACID ADJ GENERAT\$5) AND S28	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2008/03/16 14:35
S31	1500	(PHOTOACID PHOTO ADJ ACID SULFONIUM IODONIUM ACID ADJ GENERAT\$5 CATIONIC PHOTOCATIONIC) AND S28	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2008/03/16 14:36
S32	0	JP-022075621-\$ DID.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2008/03/16 14:44
S33	2	JP-02075621-\$ DID.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2008/03/16 14:44
S34	1	1994-210562.NRAN.	DERWENT	OR	OFF	2008/03/16 15:00
S35	1	2003-148555.NRAN.	DERWENT	OR	OFF	2008/03/16 18:22
S36	2	("20070296094").PN.	US-PGPUB; USPAT; DERWENT	OR	OFF	2008/03/16 19:14
S37	1	2005-495865.NRAN.	DERWENT	OR	OFF	2008/03/16 19:14
S38	2	("20050140033").PN.	US-PGPUB; USPAT; DERWENT	OR	OFF	2008/03/16 19:14
S39	2	("20050175925").PN.	US-PGPUB; USPAT; DERWENT	OR	OFF	2008/03/16 20:06
S40	0	wo-2003089991-\$ DID.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2008/03/16 20:11
S41	1	wo-03089991-\$ DID.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2008/03/16 20:11
S42	2	(("5461088") or ("5002854")).PN.	US-PGPUB; USPAT	OR	OFF	2008/03/16 20:25

3/17/08 8:07:58 AM

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